Special Issue

Recent Advances in Shale Gas Exploration, Development and Production

Message from the Guest Editors

This Special Issue, titled "Recent Advances in Shale Gas Exploration, Development and Production", aims to cover novel advances in research or practice. Topics include, but are not limited to:

- Advances in shale gas reservoir formation theory and evaluation methods;
- Design, modeling, field practice for shale gas well drilling, well completion, and simulation;
- Simulation techniques, software, algorithms, or other tools for modeling and simulation in shale gas production:
- Experiment and simulation research in shale gas exploration, development, and production.

Guest Editors

Prof. Dr. Xiangchao Shi

Dr. Wei Yan

Dr. Xian Shi

Deadline for manuscript submissions

closed (31 May 2024)



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You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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